

# Typical questions for an oral examination in IN5490 RF MEMS, 2012

(for PhD candidates, taking INF9490, see additional questions at the end of the list!)

## 1 : Modeling of RF MEMS

- Which ones are the basic modeling methods that can be used in RF MEMS design?
  - What are the characteristic features of the different methods?
- Describe the analytic modeling of a parallel plate capacitor and the pull-in effect:
  - Draw a sketch of a spring-suspended two-plate capacitor.
  - Which forces are involved when you put on a voltage between the plates?
  - When does pull-in occur and why?
  - Explain why hysteresis arises.
- Give examples of RF MEMS components where the pull-in effect is an advantage or a disadvantage? Why?

## 2: Serial contact switch in an RF signal transmission line

- Make a sketch on how you can implement a serial contact switch by a cantilever beam?
- Describe an electrostatic operation of the switch.
- Discuss some critical features:
  - Using common or separate actuation and signal electrodes
  - Pull-in voltage versus actuation voltage level
  - Stiffness of beam
  - Switching speed and damping
  - Electrical modeling
  - Aging, - reliability issues
- RF switch used in an RF transmission line:
  - Why do you need to use transmission lines for connecting components at RF signals?
  - If you have a lossless transmission line with characteristic impedance  $Z_0$  and load  $Z_{load}$ , - how can you obtain a maximum signal transmission to the load?
  - What happens with the signal in case of an open or shorted transmission line?
- Suppose a MEMS contact switch is placed serially in a transmission line having a characteristic impedance of  $Z_0$  before and after. Compute the reflection (return loss) of the signal when the switch is open (not conducting).

## 3: Shunt capacitive switch and phase shifters

- Make a sketch on how you can implement a shunt capacitive switch of type c-c beam.
- Describe the electrostatic operation of the switch.
- Discuss and comment some of the important, critical design parameters for the switch:
  - Using common or separate actuation and signal electrodes
  - Gap dimension
  - Thickness and type of dielectric material used for the capacitive switch
  - Area of overlapping electrodes
  - Pull-in voltage versus actuation voltage level
  - Stiffness of beam
  - Suspension arrangements
  - Switching speed and damping
  - Electrical modeling
  - Aging, - reliability issues
- MEMS phase shifters:
  - Typical applications where a MEMS phase shifter can be useful?
  - How can you implement a 2-bit digital MEMS phase shifter?
  - How can you implement a phase shifter based on distributed MEMS capacitances? Which parameters determine the obtainable phase shift?
  - Describe the operation of a reflection phase shifter. What are the benefits?

#### **4: Beam resonators**

- c-c beam as a resonator:
  - Describe a typical mechanical structure and operation of a c-c beam used as a resonator.
  - Why do you put on a DC voltage on the resonator beam itself? What is the effect?
  - Which factors will influence the Q-factor of the c-c beam resonator and how can you increase the Q-factor?
  - How can you increase the resonating frequency?
- free-free beam as a resonator:
  - Describe a typical mechanical structure and operation of a free-free beam used as a resonator.
  - What are the advantages of using an f-f- beam compared to a c-c- beam?
  - Which ones are the critical parameters for implementing an f-f- beam with optimal performance?

#### **5: Comb resonator and spring-mass-damper modeling**

- Lateral comb resonator:
  - Describe a typical mechanical structure and operation of a lateral comb resonator.
  - Why do you normally put on a DC voltage on the shuttle? What is the effect?

- Which parameters are critical for obtaining a high resonance frequency?
- Modeling of spring-mass-damper:
  - Draw a sketch of a typical spring-mass-damper system.
  - Set up the transfer function.
  - Which physical parameters determine the resonance frequency and Q-factor of such a system?
  - Draw a sketch and discuss an electrical equivalent of the mechanical system?

## 6: MEMS filters

- H-filter structure:
  - Describe the structure and operation of a micromechanical filter implemented as an H-structure.
  - Which factors determine the frequency and bandwidth of the H-filter?
  - Describe a typical procedure for designing such a filter, and how can the bandwidth of the filter be changed in an easy way?
- Mixer-filter structure:
  - Describe a combined MEMS mixer-filter structure.
  - Which ones are the main design parameters for such a system, and how do they influence the operation?
  - How and where can the mixer-filter block be used in a general RF transceiver?

## 7: Tunable MEMS capacitors

- What are the main, principal methods for tuning an RF MEMS capacitor?
- Describe how a 2 plate MEMS capacitor can be used as a tunable capacitor.
  - What are the restrictions, and which tuning ratio can be obtained?
- Describe how a 3 plate tunable MEMS capacitor can be implemented?
  - What are the restrictions, and which tuning ratio can be obtained?
- Do you know other gap tuning capacitor arrangements where you are able to increase the tuning ratio?
- Tunable comb capacitors:
  - Describe the structure and operation of a tunable comb capacitor.
  - What are the benefits of using such a structure compared to gap tuning?
  - Which constraints do you see?

## 8: RF MEMS inductors

- How can MEMS inductors be implemented?
  - Give examples of in- plane (2-dimensional inductor) and 3D implementations.
- Draw an equivalent circuit diagram of an RF MEMS inductor and discuss the various parasitic contributions.
  - How can the stray components (parasitics) be reduced?

- Which ones are the basic performance parameters of the RF MEMS inductors?
  - Describe important means for increasing the performance.

### **9: Integration of MEMS and IC**

- How can you combine MEMS and integrated circuits (CMOS) on a single chip (monolithic integration)?
  - Describe typical advantages and disadvantages of the main procedures.
- Describe how MEMS can be made out of an ordinary CMOS process (CMOS-MEMS).
  - What are the typical features for the CMOS-MEMS procedure used at Carnegie Mellon University (ASIMPS)?
  - Which advantages and disadvantages do you see?

### **10: RF receiver**

- Describe the typical parts of an RF receiver.
  - What are the current bottlenecks for miniaturization?
- Where can RF MEMS replace current components in a receiver block?
  - Which advantages can be obtained? What are the restrictions?
- MEMS filter bank:
  - Describe the structure and operation of an RF MEMS filter bank.
  - What are the advantages and disadvantages of using such a filter bank in a receiver?
  - Which possibilities do you see for realization?

## **Additional questions for an oral examination in INF9490 RF MEMS, 2012**

Give examples of various ways of implementing vibrating disk resonators and some of the benefits and problems with the structures.

What is the motional impedance of a mechanical resonator? What is the problem with the motional impedance level for such vibrating resonators, and how can a designer overcome this challenge?

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